# **Balanced Armature Check (BAC)**

Module of the KLIPPEL ANALYZER SYSTEM (QC Ver. 6, dB-Lab Ver. 210)

Document Revision 1.2

| FEATURES   | BENEFITS  |  |  |  |
|--|---|--|--|--|
| <ul> <li>Measure the armature offset in µm</li> <li>No additional sensor required</li> <li>Ultra-fast testing at physical limit</li> </ul> | <ul> <li>Exploit maximum working range with centered armature</li> <li>Keep distortion low</li> </ul> |  |  |  |
| Automatic limit calculation  | <ul> <li>Control production process with offset<br/>monitoring</li> </ul>                             |  |  |  |
|  | • Ensure consistency of production  |  |  |  |
|  | Fully ambient noise immune  |  |  |  |
|  | • Ready for 100% testing  |  |  |  |

The Balanced Armature Check (BAC) is an add-on task for the QC framework of the KLIPPEL Analyzer system. The BAC measures the offset of the armature and selected linear parameters of electro-magnetic transducers within an extremely short time (0.5 - 2 s).

A centered armature is required to exploit the full symmetrical working range providing maximal output. Additionally, audible distortion is reduced significantly.

The parameters are easy to interpret and provide feedback for process control to avoid manufacturing bad units.

#### Application:

- End-of-line testing
- Incoming goods inspection
- Diagnostics
- Prototyping



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## **1** Overview

| Summary   | The level of distortion generated by balanced armature transducers depends highly on<br>the rest position of the armature. By shifting the armature to its optimal position, non-<br>linear distortion can be significantly reduced. A new measurement technique is used<br>which is capable of measuring this offset in a very short time.<br>The knowledge of the offset is useful for controlling manufacturing processes and end-<br>of-line-testing, but also for the development of new products.  |
|-----------|--|
| Targets   | <ul> <li>The QC- Balanced Armature Check (BAC) was developed to satisfy the following requirements occurring under production conditions:</li> <li>Measurement of the armature offset within the shortest possible measurement time (0.5 – 2 s).</li> <li>The parameter supports limit setting and statistics (e.g. C<sub>pk</sub>, P<sub>pk</sub>) for assessing the process stability.</li> <li>QC requires a robust and cost-effective hardware solution. The BAC can be operated with the Production Analyzer or KLIPPEL Analyzer 3, which provide current and voltage sensors. No additional sensor is required for BAC.</li> <li>The purely electrical measurement principle provides high robustness against ambient noise.</li> <li>Extremely short training period for the BAC.</li> <li>The armature offset measured with the BAC can be compared with harmonic and intermodulation distortion measurements using the DIS or TRF modules which are modules of the R&amp;D framework of KLIPPEL Analyzer system. In the development process of new products, the effect of the offset on nonlinear distortion can be measured and reasonable limits can be defined for production.</li> </ul> |
| Principle | The BAC is based on a patent protected identification technique. The loudspeaker is excited by a multi-tone signal of sufficient bandwidth and amplitude. Only electrical signals (voltage and current) are measured at the terminals of the transducer. The armature offset is calculated by exploiting the nonlinear information found in the current signal. For displaying the absolute value of the offset in $\mu m$ , a mechanical calibration is necessary which is made by means importing the transduction coefficient $T_{em}$ .  |

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| Parameters at<br>x=0 | Although the device is operated at higher amplitudes and the inherent nonlinearities produce significant distortion, the parameters at the rest position x=0 can be calculated. Those parameters are comparable with the linear parameters usually measured in the small signal domain. The electrical impedance curve $Z_{el}(f)$ is also measured at the rest position of the armature where the artifacts generated by transducer nonlinearities are suppressed. |
|----------------------|---|
|                      | The BAC uses the <i>Wright</i> inductance model to model inductance behavior reliably. If desired, the simple coil inductance $L_e$ which is approximated from the <i>Wright</i> model inductance is provided as well.  |

# 2 Definitions

| Armature Offset<br>X <sub>offset</sub>            | <ul> <li>DEFINITION: The armature offset is the shift recommendation to compensate the offset relative to the magnetic field. The positive direction of excursion corresponds to the response of the BA excited with positive DC current. The definition is illustrated in the figure below.</li> <li>Note that the transduction parameter <i>T<sub>em</sub></i> defines the absolute scaling of the armature offset. See the comments on the Transduction parameter below.</li> <li>The absolute armature offset may depend also on the actual excursion used in the measurement</li> </ul>   |  |  |  |  |
|---|--|--|--|--|--|
|   | Thus, it is recommended practice reporting the voice coil offset $X_{offset}$ together with the transduction parameter $T_{em}$ and amplitude $X_{peak}$ .   |  |  |  |  |
|   | Example: X <sub>offset</sub> = 40 μm (@X <sub>peak</sub> = 200 μm)   |  |  |  |  |
|   | Diaphragm<br>Coll<br>Coll<br>Armature<br>Armature<br>Magnet 2<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Diaphragm<br>Di |  |  |  |  |
|   | Fig. 1: Schematic view of the armature offset.   |  |  |  |  |
|   | Application to end-of-line testing   |  |  |  |  |
|   | An armature offset generates 2nd-order harmonic and intermodulation distortion<br>and should be close to zero. Thus, the armature shall be well centered in the mag-<br>netic field.   |  |  |  |  |
|   | A permissible range defined by minimal or maximal QC limits may be applied to $X_{offset}$ to check for a PASS/FAIL decision.  |  |  |  |  |
| Transduction Pa-<br>rameter <i>T<sub>em</sub></i> | The absolute armature offset in $[\mu m]$ is based on the impedance measurement and one absolute mechanical parameter. This parameter is needed to calibrate the mechanical system. This parameter is specific to the BA type under test.  |  |  |  |  |

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The transduction parameter  $T_{em}$ , which is similar to the BI-factor of electro-dynamic speakers, is used in the BAC module for this purpose. This parameter can be measured or simulated.

If no  $T_{em}$  is specified, the offset is presented as a relative value in [%]. It is related to the peak displacement during the test.

#### Importing *T<sub>em</sub>* from LPM:

Using the R&D module "Linear Parameter Measurement LPM" this parameter can be measured using a displacement laser sensor.

For an accurate absolute armature offset the laser should access the excursion of the armature within the magnetic gap. In most cases this is not possible. It is common practice to use a certain point on the membrane, which is excited by a drive rod. This is not the offset of the armature inside the magnetic gap due to the leveler effect. If the mechanical details are known, the leveler effect can be compensated by a simple factor.

 $T_{em}$  strongly depends on the position of the laser target point on the membrane even for very low frequencies. The Scanner module SCN (Klippel R&D System) can be used, to assess the vibration behavior at around the resonance frequency.

#### **3** Requirements

#### 3.1 Hardware **Minimal Setup** Ambient The figure shows the minimal equipment re-Mic (opt.) quired to run the BAC: Balanced Armature KLIPPEL Analyzer 3 (KA3) QC configu-Transducer ration (alt: ALS configuration) PC Test Mic USB license dongle (opt.) Alternatively, the KLIPPEL Production Analyzer (PA) High Sensitivity version can be used together with an external power amplifier. The BAC can be combined with traditional tests such as SPL, THD, Rub&Buzz, polarity OC Card using optional microphones. **KLIPPEL** In order to use the BAC with the KLIPPEL Analyzer 3 R&D System (from version 210), the KA3 hardware is required. The analyzer is also supported from QC Version 6. It is recommended to use a KA3 with QC Card or in A(L)S configuration Amplifier Card (Laser Card) Speaker Card No external amplifier is required in this case. The required minimal card configuration for use with external amplifier is: XLR Card Speaker Card •

|                               | Please refer to the specifications of the KA3 and the extension cards for more information.  |
|-------------------------------|--|
| Production<br>Analyzer (alt.) | As an alternative to the KA3 hardware, the <i>Production Analyzer</i> also provides current and voltage sensors for two channels. To guarantee an optimal signal-to-noise ratio for balanced armature measurements, the standard current sensors may be non-ideal. The <i>High Sensitivity</i> version of the Production Analyzer is recommended.<br>Please find more information in <i>H4 – Production Analyzer Hardware</i> for detailed specification |
| Power<br>Amplifier<br>(opt.)  | Any professional audio amplifier meeting the power and bandwidth requirements of the tests may be used. An additional power amplifier is not required in case a KA3 equipped with a QC Card or an Amplifier Card.<br>Find more details in <u>KLIPPEL Amplifier Requirements</u> or specifications <u>H6 Amplifier</u> <u>Card</u> and <u>H11 QC Card</u> .   |
| PC                            | Please refer to the general recommendations in <u>KLIPPEL QC SYSTEM PC Requirements</u> .<br>The signal processing algorithms of the MSC may affect the total test time, therefore a fast<br>CPU is recommended.   |
|                               |  |

#### 3.2 Software

| QC<br>Framework  | The BAC requires QC Standard software. BAC is installed with the QC software; no addi-<br>tional setup is required. A dedicated license is required to operate the module.   |
|------------------|--|
| R&D<br>Framework | From release version 210, the BAC may be operated within the KLIPPEL RnD software re-<br>lease. No additional setup, only a BAC license is required for operation.<br><b>Note:</b> KLIPPEL Analyzer 3 (KA3) hardware is required to operate the BAC in the RnD |
|                  | software framework.  |

#### 3.3 Further Requirements

| Test Fixture              | The transducer may be measured in free air or with a closed port to achieve a better linear fitting due to the absence of potential acoustic resonances. |
|---------------------------|--|
| Acoustical<br>Environment | There are no specific requirements, the BAC is very insensitive to ambient noise.  |

#### 4 Limits

#### 4.1 Transducer

| Parameter                    | Symbol                       | Min | Тур.     | Max  | Unit |  |
|------------------------------|------------------------------|-----|----------|------|------|--|
| Coil resistance <sup>1</sup> | Re                           | 0.1 | 20 - 250 |      | Ω    |  |
| Resonance frequency          | f <sub>s</sub>               | 15  |          | 6000 | Hz   |  |
| Total loss factor            | Q <sub>ts</sub>              | 0.3 |          | 6    |      |  |
| Principle                    | Balanced Armature transducer |     |          |      |      |  |

<sup>1</sup> Maximal resistance depends on the current sensor used in the Production Analyzer

| 2 Requirements for Power Amplifier                       |  |   |    |  |  |
|--|--|---|----|--|--|
| Maximal input level 15 dBu                               |  |   |    |  |  |
| Frequency response                                       |  | 1 | dB |  |  |
| ref. 1 KHz @ 5Hz 20 kHz                                  |  |   |    |  |  |
| Input sensitivity at rated output power 0 (775) dBu (mV) |  |   |    |  |  |

# 4.3 Input Parameters (Setup)

| Parameter  | Symbol                | Min   | Тур. | Max   | Unit             |
|--|-----------------------|---|------|-------|------------------|
| rms voltage  | U <sub>rms</sub>      | 0.1   | 4    | 200   | V                |
| Driver Type  | Туре                  | <ul> <li>small BA (fs&gt;1kHz)</li> <li>large BA (fs&lt;1kHz)</li> <li>general (advanced mode)</li> </ul> |      |       |                  |
| Calibration of mechanical units <sup>2</sup>                                 | Calibration           | <ul> <li>Relative (no import required)</li> <li>T<sub>em</sub>(x=0) import</li> </ul>                     |      |       |                  |
| Transduction coefficient (if $T_{em}(x=0)$ import selected)                  | T <sub>em</sub> (x=0) | 0.01  |      |       | N/A              |
| Optional Input Parameters (if advanced mode selected)                        |                       |   |      |       |                  |
| lowest frequency of multi-tone complex                                       | f start               | 2   | 2    | 20    | Hz               |
| highest frequency of multi-tone complex                                      | $f_{ m stop}$         | 375   |      | 12000 | Hz               |
| Excitation Density (number of tones in multi-tone complex)                   | Resolution            | 1   | 20   | 200   | tones/<br>octave |
| Duration of stimulus   | Т                     | 0.17  | 0.68 | 5.46  | S                |
| Number of loops repeated the stimulus before measurement to get steady-state | T <sub>pre</sub>      | 0   | 0.5  | 20    |                  |

## **5** Measurement Results

|   | Measured Quantity        | Symbol                                 | Unit | QC limits applicable |  |  |
|---|--------------------------|--|------|----------------------|--|--|
| LARGE SIGNAL PARAMETERS (ABSOLUTE) <sup>1</sup> |                          |  |      |                      |  |  |
|   | Armature offset          | Xoffset                                | μm   | x                    |  |  |
| RELATIVE LARGE SIGNAL PARAMETERS (RELATIVE)     |                          |  |      |                      |  |  |
|   | Relative armature offset | $X_{offset}/max(X_{peak}, X_{bottom})$ | %    | x                    |  |  |
| PARAMETERS AT THE REST POSITION (X=0)           |                          |  |      |                      |  |  |
|   | Voice coil resistance    | Re                                     | Ohm  | x                    |  |  |
|   | Resonance frequency      | fs                                     | Hz   | x                    |  |  |
|   | Total loss factor        | Qts                                    |      | х                    |  |  |

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|                   | Impedance curve                          | Z <sub>el</sub> (f) | Ohm | х |  |
|-------------------|--|---------------------|-----|---|--|
|                   | Inductance of the LR2 Model <sup>3</sup> | Le                  | mH  | х |  |
| STATE INFORMATION |  |                     |     |   |  |
|                   | Peak Current                             | I <sub>peak</sub>   | А   |   |  |
|                   | Peak Voltage                             | Upeak               | V   |   |  |
|                   | Positive Peak Displacement <sup>1</sup>  | X <sub>peak</sub>   | μm  |   |  |
|                   | Negative Peak Displacement <sup>1</sup>  | X <sub>bottom</sub> | μm  |   |  |
|                   | Headroom Current                         | Hi                  | dB  |   |  |
|                   | Distortion Current                       | Di                  | dB  |   |  |

<sup>1</sup> Additional information about the mechanical system is required (import  $T_{em}$  at x=0)

<sup>2</sup> Absolute identification of the mechanical parameters without laser sensor requires import of  $T_{em}(x=0)$ 

<sup>3</sup> The coil inductance is only approximated from the Wright model to deliver an easy interpretable parameter. Balanced Armature inductances cannot be described by the simple  $L_e$  inductance model in general.

## 6 Patents

| Germany | 102013012811  |
|---------|---------------|
| USA     | 14/499,379    |
| China   | 2014103769646 |
| Korea   | 1020140095591 |

Find explanations for symbols at: http://www.klippel.de/know-how/literature.html Last updated: July 03, 2019

